

ABSTRACT**POSITIVE TYPE PHOTOSENSITIVE SILOXANE COMPOSITION AND CURED FILM FORMED BY USING THE SAME**

To provide a positive type photosensitive composition capable of forming a cured film having high transparency 0 [Means] The present invention provides a positive type photosensitive siloxane composition comprising: a polysiloxane, a diazonaphthoquinone derivative, an additive having a $>\text{N}-\text{C}(=\text{O})$ -or $>\text{N}-\text{C}(=\text{S})$ -structure and the capability of interacting with the polysiloxane, 0 and a solvent. The polysiloxane and the additive interact with each other before exposure, but they lose the interaction after exposure.

(No figure)